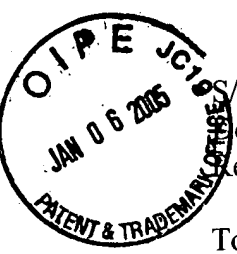


IFW



S/N: 10/ 768,612  
Docket: CS03-048  
Reply to the Office action dated Dec. 28, 2004

To: Commissioner of Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

5 From: William J. Stoffel 1735 Market St - Ste A  
Reg no. 39,390 PMB 455  
Customer no. 30,402 Philadelphia, PA 19103 USA

10 Subject:

S/N: 10/ 768,612  
Docket: CS03-048  
Reply to the Office action dated Dec. 28, 2004  
File date: 1/30/04  
Inventor: Yisuo Li  
Title : **A SEMICONDUCTOR DEVICE LAYOUT AND  
CHANNELING IMPLANT PROCESS**  
  
Group Art Unit: 2812  
Examiner: Lindsay Jr., Walter Lee

**RESPONSE TO PATENT OFFICE ACTION**

15 Dear Sir:

In response to the office action dated 12 /28 /2004, please consider the following remarks:

**CERTIFICATE OF MAILING OR FACSIMILE TRANSMISSION**

I hereby certify that this correspondence is being :

20 ☐ FAXED to the central facsimile number of patent and trademark office at the following number 703) 872-9306 or  
☒ deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on January 4, 2005.

25 Signature/Date William J. Stoffel 1/4/05 January 4, 2005.  
William J. Stoffel Reg. No. 39,390 Customer number 30402

S/N: 10/ 768,612 .

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Docket: CS03-048

Reply to the Office action dated Dec. 28, 2004

**This response to Office Action has the following sections:**

- **Amendments to the claims** begin the next page of this paper
- **Remarks/Arguments** begin on the page following the amendments to the claims.